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Applicant(s): Yasushi A	KIYAMA et al.		2002JP311
Serial No.	Filing Date	Examiner	Group Art Unit
10/519,242	December 22, 2004	WU, Ives J.	1713
Pention: COMPOSIT	TON FOR ANTIREFLECTIVE	COATING AND METHOD FO	OR FORMING SAME
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(21)Application number: 03-250201 (71)Applicant: ASAHI GLASS CO LTD

(22)Date of filing: 04.09.1991 (72)Inventor: AOSAKI KOU

YOKOZUKA TOSHISUKE

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(30)Priority

Priority number: 03202337

Priority date: 17.07.1991

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(54) PATTERN FORMING METHOD

(57)Abstract:

PURPOSE: To provide a pattern forming method by which multiple interference of light which becomes an obstacle for fine patterning can be extremely reduced, the manufacturing yield can be improved, and a fine pattern can be effectively formed.

CONSTITUTION: In this pattern forming method, exposure is performed after forming a reflection preventing film on the surface of a photoresist at the time of forming a pattern by photolithography. An amorphous fluorine-bearing polymer is used for forming the reflection preventing film.

LEGAL STATUS [Date of request for examination] 31.08.1998

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